WHAT IS CLAIMED IS:

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1. A color cathode ray tube comprising:

a mask frame;

a shadow mask fixed to the mask frame;

an inner magnetic shield supported by the mask frame; and

an electron shield provided in the mask frame;

wherein at least a part of the electron shield has a smaller anhysteretic magnetic permeability than the shadow mask, the mask frame and the inner magnetic shield when an applied magnetic field is 800 A/m (10 Oe).

- 2. The color cathode ray tube according to claim 1, wherein the electron shield is formed so as to elongate a front end portion on an electron beam side of the mask frame.
- 3. The color cathode ray tube according to claim 1, wherein the electron shield is formed of a member different from the mask frame so as to protrude beyond a front end portion on an electron beam side of the mask frame.

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4. The color cathode ray tube according to claim 1, wherein a part of the electron shield has a region having a smaller anhysteretic magnetic permeability than another part when the applied magnetic field is 800 A/m (10 Oe).

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- 5. A color cathode ray tube comprising:
 - a mask frame;
 - a shadow mask fixed to the mask frame;
 - an inner magnetic shield supported by the mask frame; and
 - an electron shield provided in the mask frame;

wherein at least a part of the electron shield has a smaller anhysteretic magnetic permeability than the shadow mask, the mask frame and the inner magnetic shield when an applied magnetic field is 800 A/m (10 Oe), and

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the mask frame comprises a L-shaped member having a L-shaped cross-section and a reinforcing member connected with the L-shaped

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member, and a part of the reinforcing member has a region having a smaller anhysteretic magnetic permeability than another part when the applied magnetic field is 800 A/m (10 Oe).

- 5 6. A color cathode ray tube comprising:
 a mask frame;
 a shadow mask fixed to the mask frame;
 an inner magnetic shield supported by the mask frame; and
 an electron shield provided in the mask frame;
- wherein at least a part of the electron shield has a smaller anhysteretic magnetic permeability than the shadow mask, the mask frame and the inner magnetic shield when an applied magnetic field is 800 A/m (10 Oe), and
 - when an electron beam scans a phosphor screen at 100 %, a minimum distance between the electron shield and a path of the electron beam is at least 8 mm.